

Electronic Supporting Information

Highly efficient iridium(III) phosphors with 2-(4-benzylphenyl)pyridine-type ligand and their high-performance organic light-emitting diodes

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Experimental section

General procedures and materials: All reactions were performed under an inert nitrogen atmosphere with the use of a Schlenk line. Glasswares were dried in oven prior to use. Commercially available reagents were used without purification unless otherwise stated. Solvents were purified by distillation over appropriate drying agents. All reactions were monitored by thin-layer chromatography (TLC) with Merck pre-coated aluminum plates. Products were separated and purified by column chromatography with silica gel. Compounds Ir(acac)₃, IrCl₃·3H₂O, K₂PtCl₄, Pd(PPh₃)₄, 4-bromobenzylbromide and other starting materials were commercially available and used as received unless otherwise specifically mentioned. The aryl boronic acid was prepared as reported by the literature method.¹

Physical measurements: Fast atom bombardment (FAB) mass spectra were recorded on a Finnigan MAT SSQ710 system. Proton and carbon NMR spectra were measured in CDCl₃ on a Bruker Ultra-shield 400 MHz spectrometer and tetramethylsilane (TMS) was used as an internal standard for chemical shift calibration. UV/Vis spectra were recorded on a Hewlett Packard 8453 spectrometer. The photoluminescent properties of the compounds were examined using PTI Time Master Model C-720 spectrometer. The photoluminescence quantum yields were investigated in degassed CH₂Cl₂ solution at 298 K against *fac*-[Ir(ppy)₃] standard ($\Phi_p = 0.40$). For lifetime measurements, the 337 nm line of a N₂ laser was used as an excitation light source. The data were analyzed by iterative convolution of the luminescence decay profile with the instrument response function using a software package provided by PTI instruments. Electrochemical measurements were conducted

on Potentiostat/Galvanostat/EIS Analyzer model Parstat 4000 at a scan rate of 50 mV s⁻¹. A conventional compartment cell equipped with a carbon glassy working electrode, platinum wire counter electrode and Ag/Ag⁺ reference electrode was used. 0.1 M [Bu₄N]PF₆ in THF solution and ferrocene were used as a supporting electrolyte and an internal standard, respectively. The HOMO and LUMO energy levels were determined from the oxidation (E_{ox}) and reduction (E_{red}) potentials using the equations $E_{HOMO} = -(E_{ox} + 4.8)$ eV and $E_{LUMO} = -(E_{red} + 4.8)$ eV which were calculated using the internal standard ferrocene value of -4.8 eV with respect to the vacuum level.² Differential scanning calorimetry (DSC) was performed on a Perkin Elmer Pyris Diamond DSC unit under a nitrogen flow at a heating rate of 20 °C min⁻¹ to obtain the glass transition temperature (T_g). The thermal gravimetric analysis (TGA) was conducted on Perkin Elmer TG-6 instrument under nitrogen at the heating rate of 5 °C min⁻¹.

General procedures for OLED fabrication and measurements: The devices were fabricated by sequentially depositing organic layers under high vacuum thermal evaporation on pre-cleaned indium tin oxide (ITO) glass substrates which were treated with ozone for 10 min. For monochromatic OLEDs manufactured by vacuum deposition, the NPB layer was deposited on a 10 nm MoO₃ thin layer pre-coated on the ITO glass. Then the TCTA layer was placed on the NPB layer. The metallophosphor dopant and host material were co-evaporated to form the emitting layer. TPBi, LiF and Al were evaporated and deposited one by one. All experiments and measurements were performed at room temperature under ambient conditions. The EL spectra and luminance were measured with a PR 650 Spectra Scan spectrometer. The current density-voltage (L - V) characteristics of the devices were

recorded using a Keithley 2400/2000 source meter.

Synthesis of cyclometalating ligands L1–L5

Synthesis of L1

The commercially available 4-bromobenzyl bromide (1.12 g, 4.52 mmol) reacted with one equivalent of phenylboronic acid (0.55 g, 4.52 mmol) in the presence of Pd(PPh₃)₄ (80 mg) in the solution of toluene (40 mL), ethanol (20 mL) and 2 M Na₂CO₃ (3 mL). A two-necked flask containing 4-benzylphenyl bromide (0.80 g, 3.62 mmol) in dry tetrahydrofuran was cooled in an ice-acetone bath under a nitrogen atmosphere. Then *n*-butyllithium was added to the flask dropwisely followed by trimethylborate and diluted hydrochloric acid. 4-Benzylphenyl boronic acid (0.54 g, 2.53 mmol) was prepared, treated with 2-bromopyridine (0.31 g, 1.95 mmol) through the Suzuki coupling reaction to yield the target compound. The reaction mixture was extracted with ethyl acetate and washed with deionized (D.I.) water. The organic layer was dried over anhydrous Na₂SO₄. The solvent was filtered and then concentrated under vacuum. The mixture was purified by a silica gel column chromatography to afford the white solid product (67%).

Spectral data: MS (MALDI-TOF): *m/z* 245.12 (M⁺). ¹H NMR (CDCl₃): δ (ppm) 7.80 (d, *J* = 8.0 Hz, 3H, Ar), 7.57–7.53 (m, 6H, Ar), 7.50 (d, *J* = 5.6 Hz, 3H, Ar), 7.10–7.02 (m, 15H, Ar), 6.83 (s, 6H, Ar), 6.63 (d, *J* = 8.4 Hz, 3H, Ar), 3.73–3.70 (m, 6H, CH₂).

Synthesis of L2

A reaction flask was charged with ethanol (20 mL), toluene (40 mL), 4-bromobenzyl bromide (1.18 g, 4.78 mmol) and *p*-tolylboronic acid (0.65 g, 4.78

mmol). The flask was evacuated and filled with nitrogen and then 2 M solution of Na_2CO_3 (3 mL) and $\text{Pd}(\text{PPh}_3)_4$ (80 mg) were added. The reaction mixture was stirred at 80 °C for 15 h. 1-Bromo-4-(4-methylbenzyl)benzene was then purified and then converted to its boronic acid derivative. A mixture of 4-(4-methylbenzyl)phenylboronic acid (0.61 g, 2.68 mmol) and 2-bromopyridine (0.32 g, 2.06 mmol) and tetrahydrofuran was charged with nitrogen, after which a catalytic amount of $\text{Pd}(\text{PPh}_3)_4$ was added. The mixture was stirred for two days at 110 °C. After cooling to room temperature, the mixture was washed with D.I. water and extracted with ethyl acetate. The combined organic layer was dried by Na_2SO_4 , filtered and concentrated. After purification by a silica gel column chromatography with a mixture of hexane: CH_2Cl_2 (5:1 v/v), the targeted compound was obtained as a white powder (72%).

Spectral data: MS (MALDI-TOF): m/z 259.14 (M^+). ^1H NMR (CDCl_3): δ (ppm) 8.67–8.66 (m, 1H, Ar), 7.90 (d, $J = 8.4$ Hz, 2H, Ar), 7.75–7.68 (m, 2H, Ar), 7.29 (d, $J = 8.4$ Hz, 2H, Ar), 7.22–7.19 (m, 1H, Ar), 7.10 (s, 4H, Ar), 4.00 (s, 2H, CH_2), 2.32 (s, 3H, CH_3).

Synthesis of L3

This compound was obtained using the same methodology as described in L1 but 4-benzylphenylboronic acid (1.20 g, 5.66 mmol) and 2-chloro-4-methylpyridine (0.55 g, 4.35 mmol) were used instead. The 4-methyl-2-(4-benzylphenyl)pyridine was purified by silica gel chromatography eluting with a mixture of hexane: CH_2Cl_2 (3:1, v/v) as a pale yellow oil (66%).

Spectral data: MS (MALDI-TOF): m/z 259.14 (M^+). ^1H NMR (CDCl_3): δ (ppm) 8.52 (d, $J = 5.6$ Hz, 1H, Ar), 7.89 (d, $J = 8.4$ Hz, 2H, Ar), 7.51 (s, 1H, Ar), 7.30–7.28

(m, 4H, Ar), 7.22–7.20 (m, 3H, Ar), 7.04 (d, $J = 5.6$ Hz, 1H, Ar), 4.04 (s, 2H, CH₂), 2.40 (s, 3H, CH₃).

Synthesis of L4

This compound was obtained using the same methodology as described in L1 but 4-benzylphenylboronic acid (1.10 g, 5.19 mmol) and 2-chloro-5-methylpyridine (0.51 g, 3.99 mmol) were used instead. The 5-methyl-2-(4-benzylphenyl)pyridine was purified by silica gel chromatography eluting with a mixture of hexane:CH₂Cl₂ (3:1, v/v) as a white powder (76%).

Spectral data: MS (MALDI-TOF): m/z 259.14 (M⁺). ¹H NMR (CDCl₃): δ (ppm) 8.49 (s, 1H, Ar), 7.88 (d, $J = 8.4$ Hz, 2H, Ar), 7.69 (d, $J = 8.0$ Hz, 1H, Ar), 7.53 (d, $J = 10.4$ Hz, 1H, Ar), 7.31–7.25 (m, 4H, Ar), 7.20 (d, $J = 6.8$ Hz, 3H, Ar), 4.03 (s, 2H, CH₂), 2.36 (s, 3H, CH₃).

Synthesis of L5

This compound was obtained using the same methodology as described in L1 but 2-chloro-5-trifluoromethylpyridine (0.79 g, 4.35 mmol) and 4-benzylphenylboronic acid (1.20 g, 5.66 mmol) were used instead. 5-Trifluoromethyl-2-(4-benzylphenyl)pyridine was purified by silica gel chromatography eluting with a mixture of hexane:CH₂Cl₂ (2:1, v/v) as a white powder (64%).

Spectral data: MS (MALDI-TOF): m/z 313.11 (M⁺). ¹H NMR (CDCl₃): δ (ppm) 8.95 (s, 1H, Ar), 8.08 (d, $J = 12.4$ Hz, 2H, Ar), 7.94 (d, $J = 2.0$ Hz, 1H, Ar), 7.81 (d, $J = 8.0$ Hz, 1H, Ar), 7.37–7.32 (m, 4H, Ar), 7.32–7.24 (m, 3H, Ar), 4.08 (s, 2H, CH₂).

Table S1. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **1** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.76/449	0.0222	H→L	0.63235
	S ₀ →S ₅	3.17/391	0.0279	H-1→L+1	0.65534
				H-1→L	0.21324
	S ₀ →S ₁₀	3.51/354	0.0268	H-2→L	0.57317
	S ₀ →S ₁₃	3.64/340	0.0537	H-2→L+2	0.19555
	S ₀ →S ₂₂	4.00/310	0.0464	H-4→L+3	0.23097
	S ₀ →S ₂₄	4.05/306	0.0830	H-4→L+2	0.40936
				H-2→L+2	0.19317
	S ₀ →S ₂₇	4.1762/297	0.0824	H-6→L+1	0.37976

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

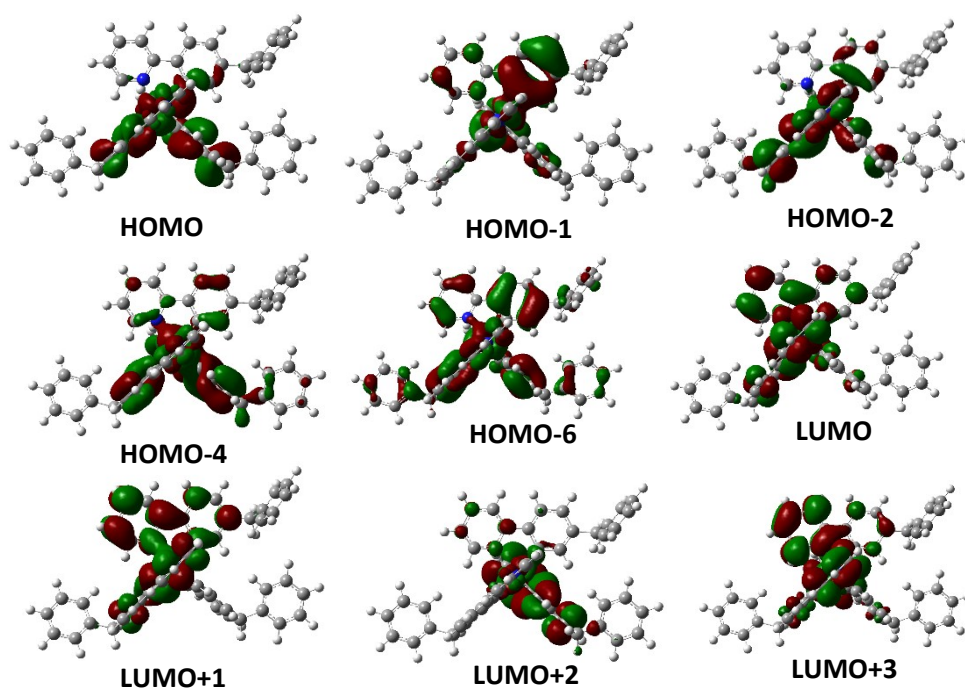


Fig. S1 Electron density maps of the frontier molecular orbital of the complex **1** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S2. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **2** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.76/449	0.0224	H→L	0.62347
	S ₀ →S ₃	2.93/424	0.0165	H→L+2	0.68206
	S ₀ →S ₇	3.37/368	0.0287	H-1→L+2	0.54180
	S ₀ →S ₁₃	3.64/341	0.0551	H-3→L	0.50437
				H-4→L	0.30676
	S ₀ →S ₂₄	4.03/307	0.0889	H-4→L+2	0.38142
				H-3→L+3	0.12600
	S ₀ →S ₂₇	4.16/298	0.1237	H-6→L+1	0.34567
			H-6→L	0.31726	

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

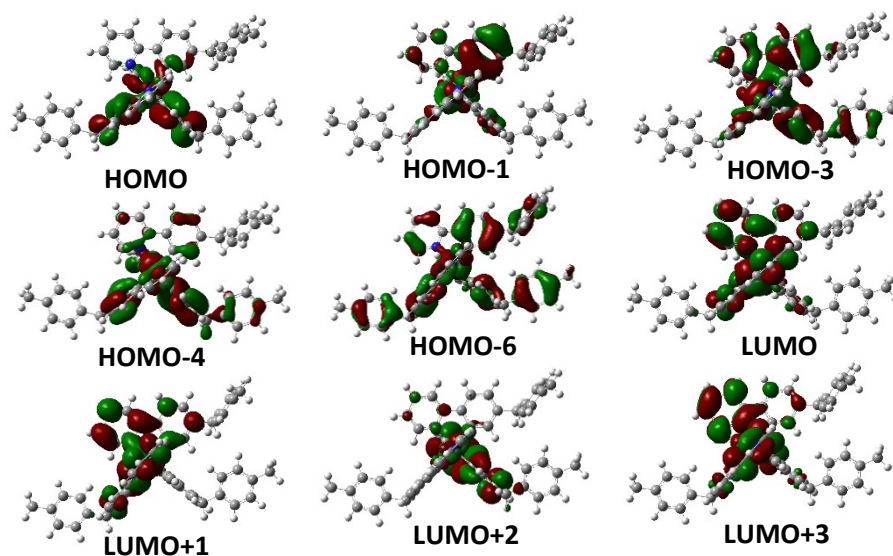


Fig. S2 Electron density maps of the frontier molecular orbital of the complex **2** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S3. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **3** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.83/438	0.0268	H→L	0.66255
	S ₀ →S ₃	2.96/418	0.0155	H→L+2	0.68284
	S ₀ →S ₄	3.18/390	0.0351	H-1→L	0.68407
	S ₀ →S ₁₃	3.66/338	0.0399	H-3→L	0.48312
				H-2→L+2	0.26565
	S ₀ →S ₁₈	3.84/322	0.0559	H-3→L+2	0.44683
				H-2→L+2	0.31953
	S ₀ →S ₂₃	4.07/304	0.0620	H-4→L+2	0.45614
	S ₀ →S ₂₇	4.21/295	0.0740	H-6→L+1	0.32614

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

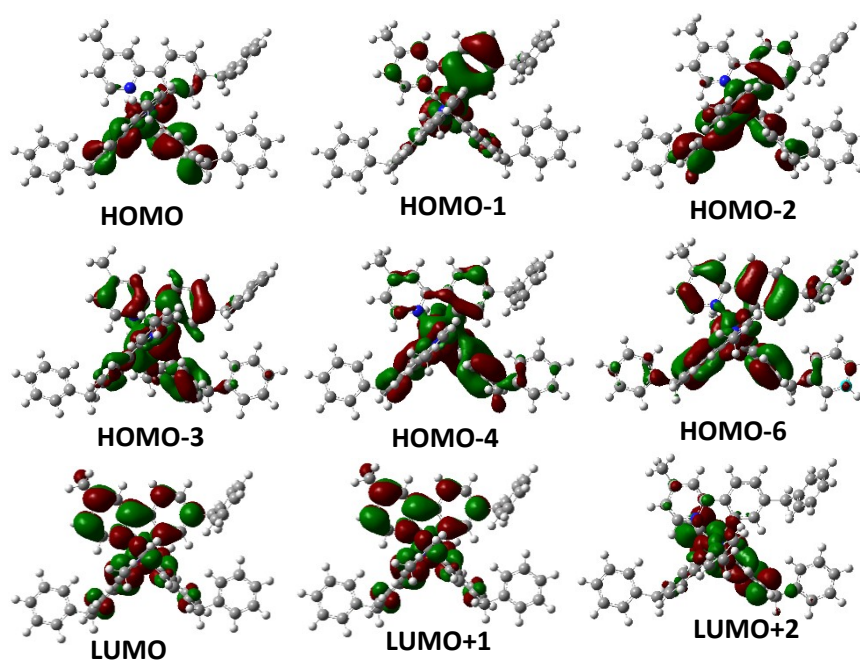


Fig. S3 Electron density maps of the frontier molecular orbital of the complex **3** Based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S4. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **4** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.76/449	0.0213	H→L	0.59737
				H→L+1	0.36140
	S ₀ →S ₃	2.92/424	0.0176	H→L+2	0.68345
	S ₀ →S ₉	3.43/362	0.0559	H-1→L+2	0.46236
	S ₀ →S ₁₃	3.63/343	0.0485	H-3→L	0.51084
	S ₀ →S ₂₄	4.01/309	0.0904	H-3→L+2	0.34895
	S ₀ →S ₂₇	4.13/300	0.0616	H-6→L+1	0.37768
			H-2→L+5	0.27070	

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

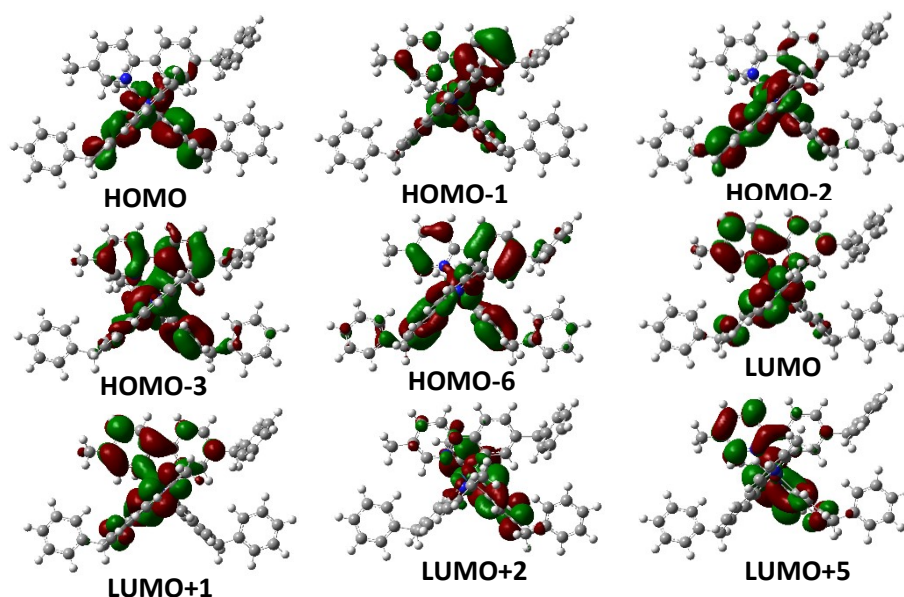


Fig. S4 Electron density maps of the frontier molecular orbital of the complex **4** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S5. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **5** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.88/430	0.0076	H→L	0.68331
	S ₀ →S ₃	3.14/394	0.0182	H-2→L	0.68935
	S ₀ →S ₉	3.60/344	0.0395	H-3→L	0.46776
				H→L+4	0.42172
	S ₀ →S ₁₆	3.93/316	0.0308	H-2→L+2	0.39441
	S ₀ →S ₁₈	3.96/313	0.0822	H-4→L+1	0.54593
	S ₀ →S ₂₇	4.28/289	0.2253	H-6→L+1	0.51292
			H-3→L+2	0.23942	

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

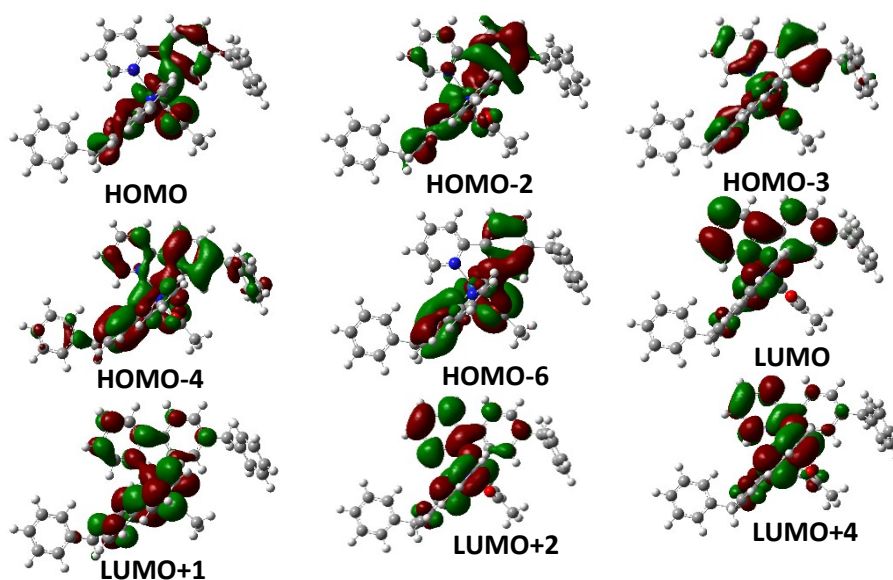


Fig. S5 Electron density maps of the frontier molecular orbital of the complex **5** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S6. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **6** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.89/429	0.0072	H→L	0.68400
	S ₀ →S ₃	3.15/393	0.0215	H-1→L	0.68910
	S ₀ →S ₉	3.61/344	0.0363	H→L+4	0.46524
	S ₀ →S ₁₈	3.95/314	0.0928	H-4→L+2	0.56995
	S ₀ →S ₂₀	4.01/309	0.0334	H-5→L	0.46970
	S ₀ →S ₂₇	4.27/291	0.1741	H-6→L+1	0.56997

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

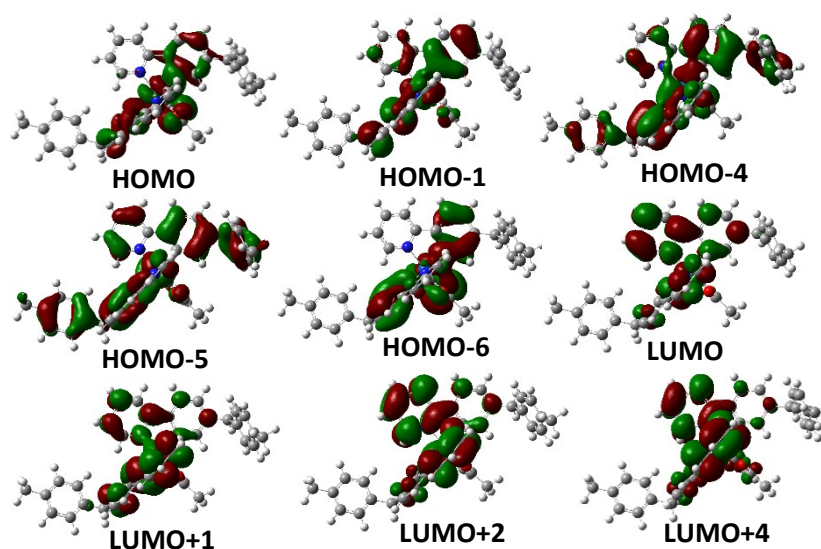


Fig. S6 Electron density maps of the frontier molecular orbital of the complex **6** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S7. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **7** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.90/427	0.0088	H→L	0.68068
	S ₀ →S ₃	3.17/392	0.0209	H-1→L	0.68903
	S ₀ →S ₉	3.61/343	0.0781	H-2→L	0.63745
	S ₀ →S ₁₉	4.00/310	0.0524	H-4→L+1	0.39485
				H-2→L+2	0.28300
	S ₀ →S ₂₃	4.17/297	0.0463	H-5→L+1	0.55766
	S ₀ →S ₂₇	4.30/288	0.2523	H-3→L+2	0.24657
				H-5→L	0.22219

^a Only the selected low-lying excited states are presented. ^bOscillator strengths. ^cOnly the main configurations are presented. ^dThe CI coefficients are in absolute values.

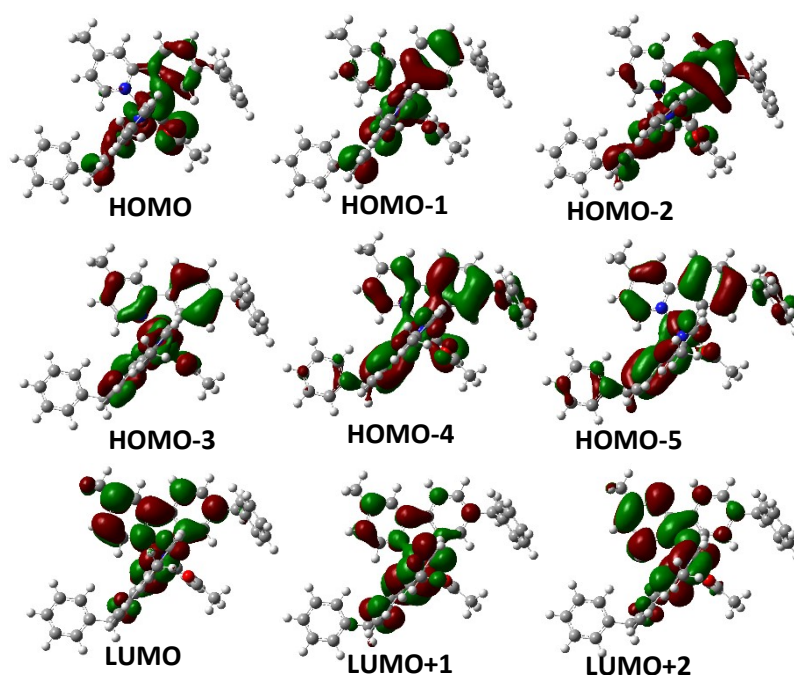


Fig. S7 Electron density maps of the frontier molecular orbital of the complex **7** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S8. Electronic excitation energies (eV) and corresponding oscillator strengths (f) main configurations and CI coefficients of the low-lying electronic excited states of the complex **8** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.88/431	0.0079	H→L	0.68835
	S ₀ →S ₃	3.15/393	0.0216	H-1→L	0.68890
	S ₀ →S ₉	3.61/343	0.0641	H-3→L	0.60544
	S ₀ →S ₁₇	3.96/313	0.0364	H-2→L+2	0.33306
	S ₀ →S ₂₀	4.03/308	0.0772	H-5→L	0.45695
	S ₀ →S ₂₇	4.29/289	0.1994	H-6→L+1	0.54541
				H-3→L+2	0.23368

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

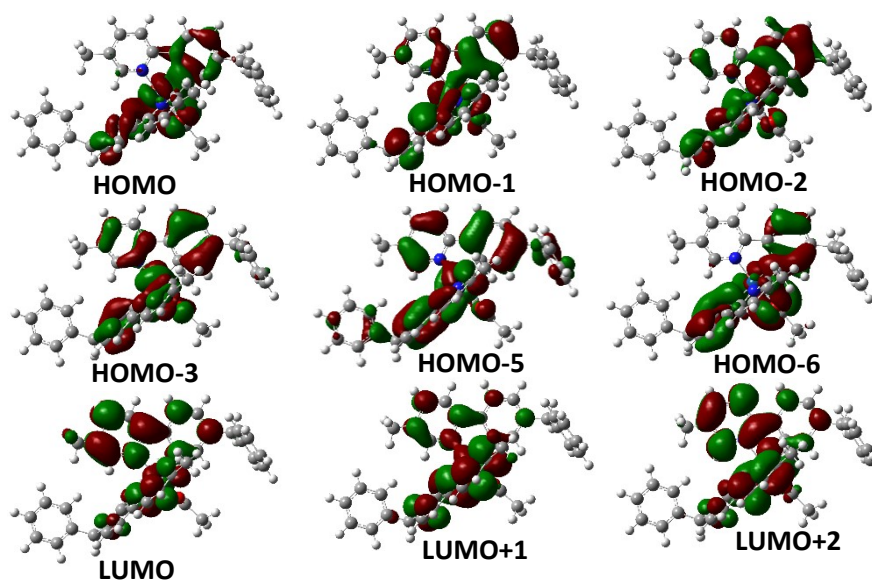


Fig. S8 Electron density maps of the frontier molecular orbital of the complex **8** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

Table S9. Electronic excitation energies (eV) and corresponding oscillator strengths (f), main configurations and CI coefficients of the low-lying electronic excited states of the complex **9** calculated by TDDFT//B3LYP/GENECP based on the DFT//B3LYP/GENECP optimized ground state geometries

	Electronic transition	Energy [eV/nm] ^a	f^b	Composition ^c	CI ^d
Singlet	S ₀ →S ₁	2.63/471	0.0066	H→L	0.70106
	S ₀ →S ₃	3.01/412	0.0267	H-1→L	0.69151
	S ₀ →S ₁₀	3.45/360	0.0761	H-3→L	0.60845
				H-1→L+2	0.20766
	S ₀ →S ₁₆	3.77/329	0.0781	H-4→L+1	0.58668
				H-3→L+2	0.20620
	S ₀ →S ₂₃	4.00/310	0.0711	H-6→L+1	0.39779
				H-5→L	0.26333
	S ₀ →S ₂₈	4.14/300	0.0117	H-4→L+2	0.44028

^a Only the selected low-lying excited states are presented. ^b Oscillator strengths. ^c Only the main configurations are presented. ^d The CI coefficients are in absolute values.

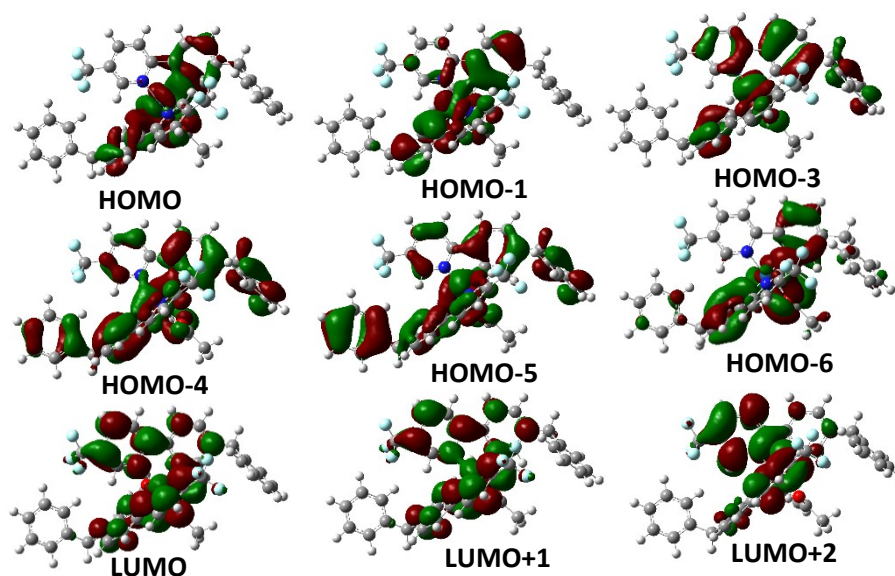


Fig. S9 Electron density maps of the frontier molecular orbital of the complex **9** based on ground state optimized geometry by the DFT calculations at the B3LYP/GENECP level with Gaussian 09W.

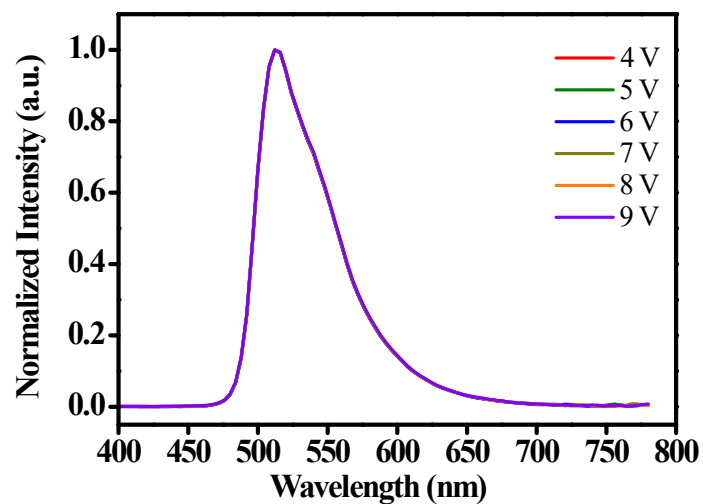


Fig. S10 Voltage independent EL spectra of **4**.

References:

1. S. J. Liu, Q. Zhao, Q. L. Fan and W. Huang, *Eur. J. Inorg. Chem.*, 2008, **13**, 2177.
2. R. S. Ashraf, M. Shahid, E. Klemm, M. Al-Ibrahim, S. Sensfuss, *Macromol. Rapid Commun.*, 2006, **27**, 1454.